

High-resistivity CMOS pixel sensors and their application to the STAR PIXEL detector

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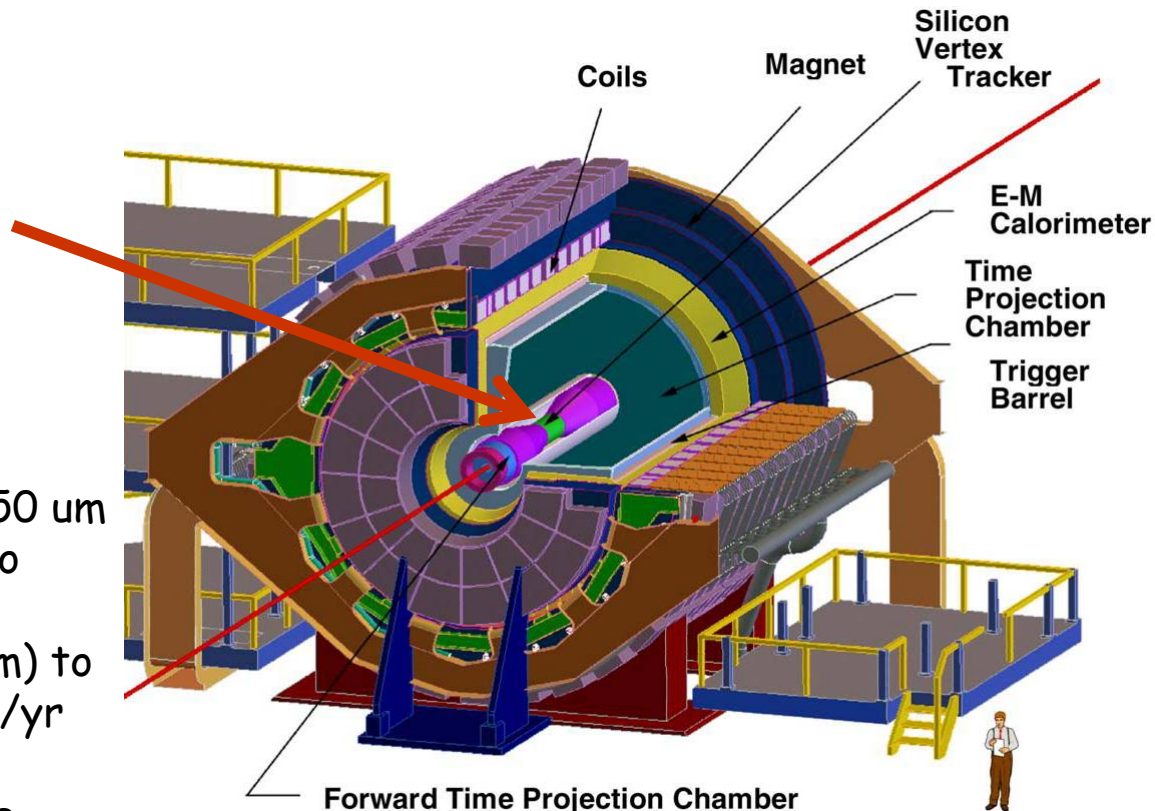
- Requirements for the Heavy Flavour Tracker of the STAR experiment (see also L.Greiner's talk)
- Monolithic Active Pixel Sensors, EUDET Beam telescope
- EUDET BT sensor as a prototype for STAR implemented in a high resistivity epitaxial layer
- Prototyping the pixel optimisation for the STAR sensor (called ULTIMATE)
- Conclusions and perspectives

STAR experiment and Heavy Flavour Tracker

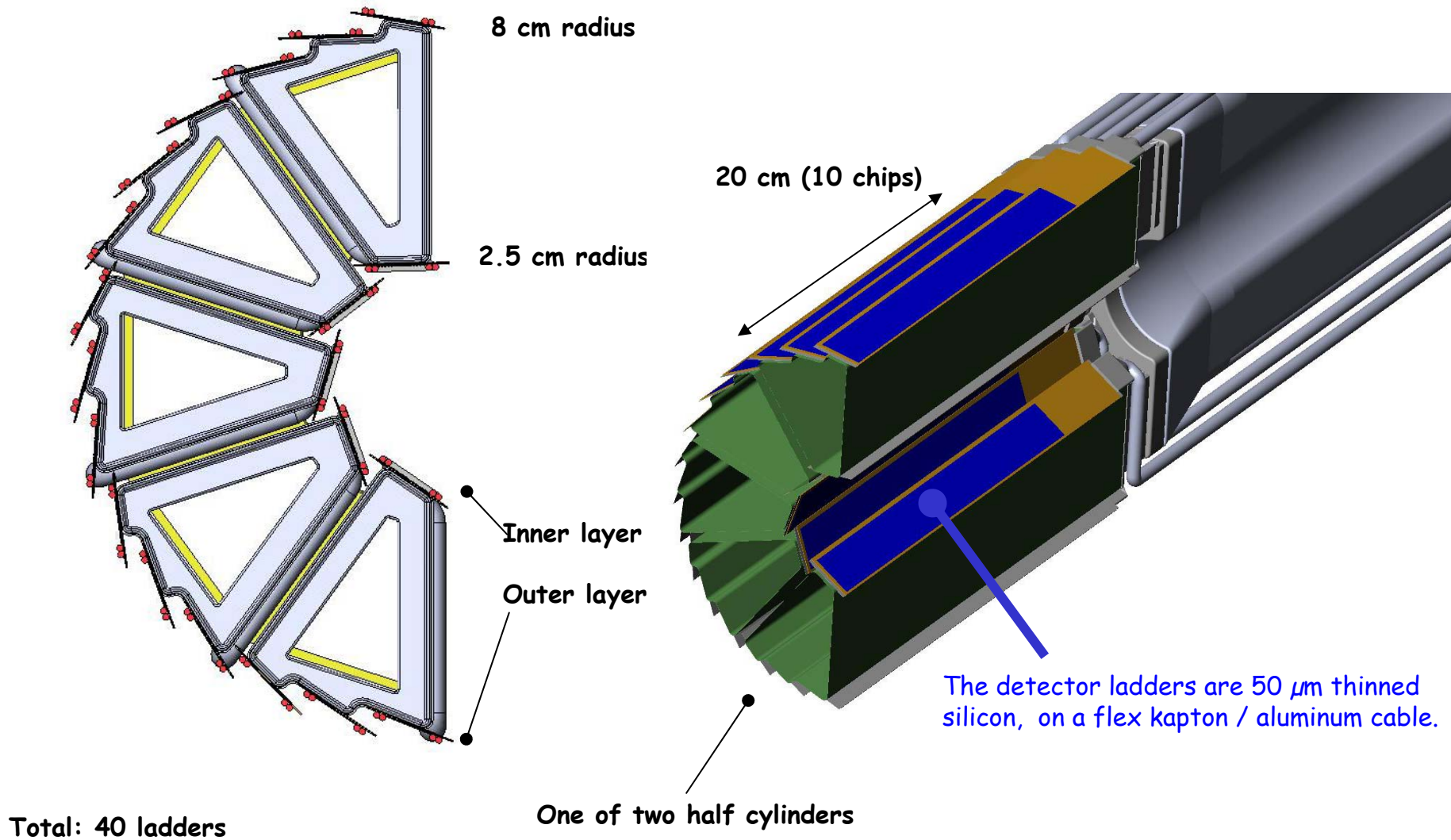
The STAR (Solenoidal Tracker At RHIC) experiment at the Relativistic Heavy Ion Collider (RHIC) studies the new state of matter produced in relativistic heavy ion collisions.

The Heavy Flavour Tracker (HFT) will use 2 cylindrical monolithic active pixel sensors (MAPS) layers for the vertex detector upgrade

- small radiation length: thinned to 50 μm on a flex kapton/aluminium cable to minimize multiple scattering
- sensors positioned close (2.5 - 8 cm) to the interaction region ($\sim 150 \text{ kRad/yr}$ and $3e12 \text{ Neq/cm}^2$)
- resolution sufficient to resolve the secondary decay vertices from the primary vertex ($< 10 \mu\text{m}$)
- work at ambient ($\sim +35 \text{ C}$) temperature



PIXEL detector geometry



Monolithic Active Pixel Sensors

Matrix of charge collecting Nwell Diodes

Particle traverses the sensing volume

Readout circuits - standard CMOS technology

epitaxial layer (p-doped)

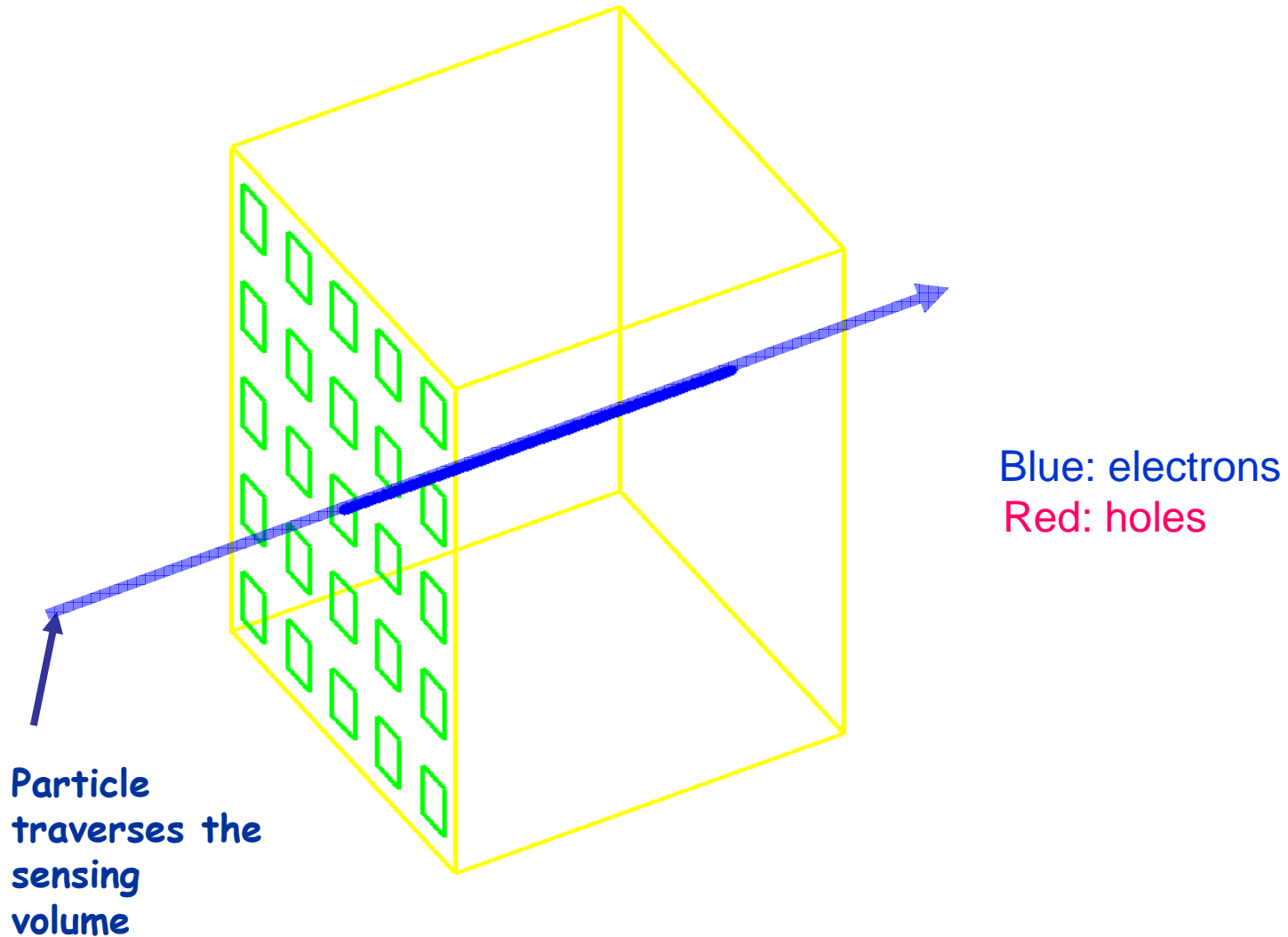
Under development since 1999 at IPHC (Strasbourg):

1. MAPS implemented in standard CMOS substrate with readout electronics
2. use p-epitaxial layer as sensing volume ($\sim 10\text{-}20\ \mu\text{m}$)
3. Nwell Diodes collect e-h pair liberated by the particle

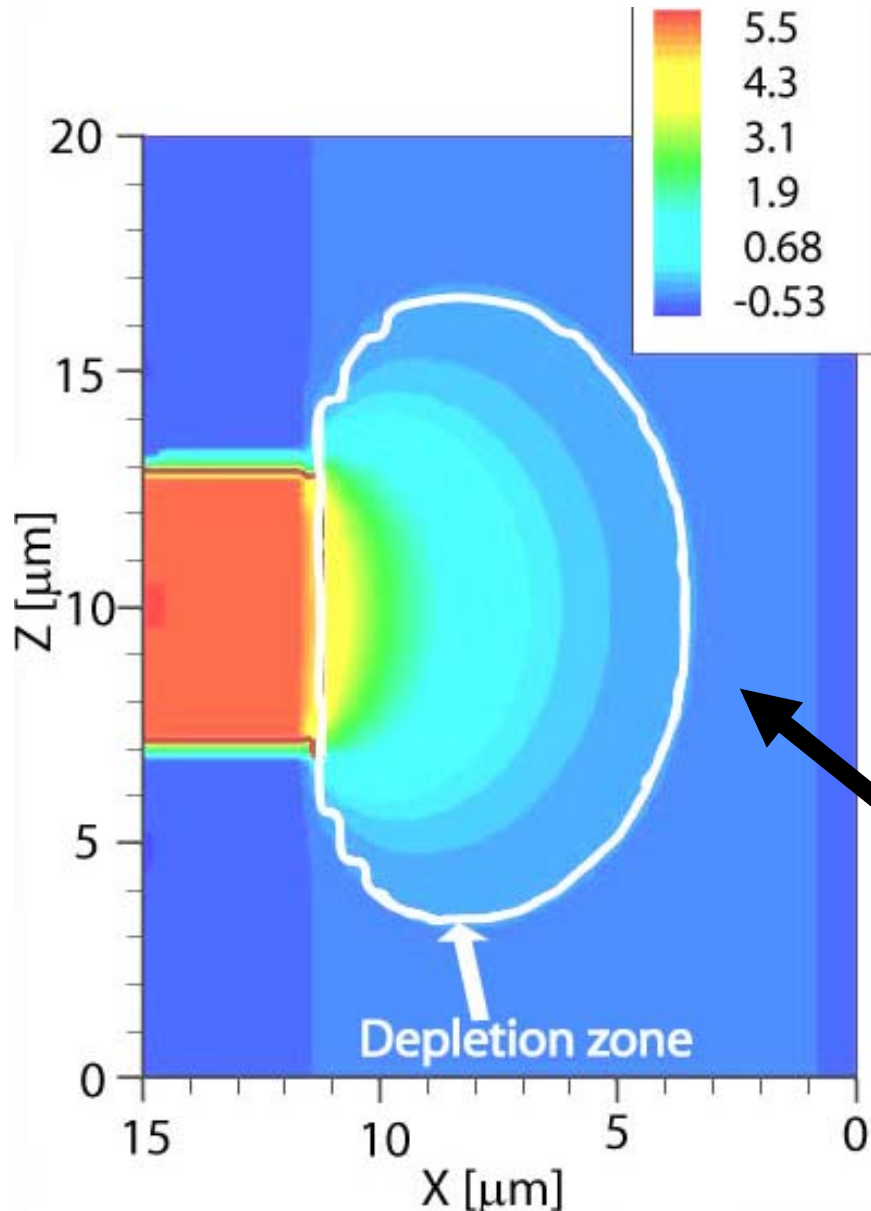


- low cost
- high granularity
- low material budget
- in-pixel signal amplification
- low noise
- integrated readout and signal processing

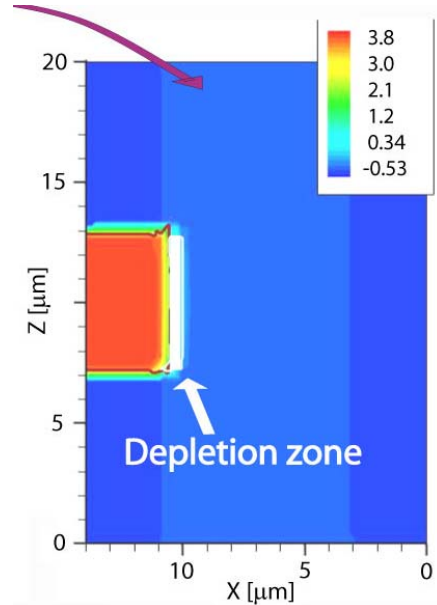
Monolithic Active Pixel Sensors: charge collection



MAPS in a high resistivity epitaxial layer



For comparison: standard CMOS technology, low resistivity P-epi

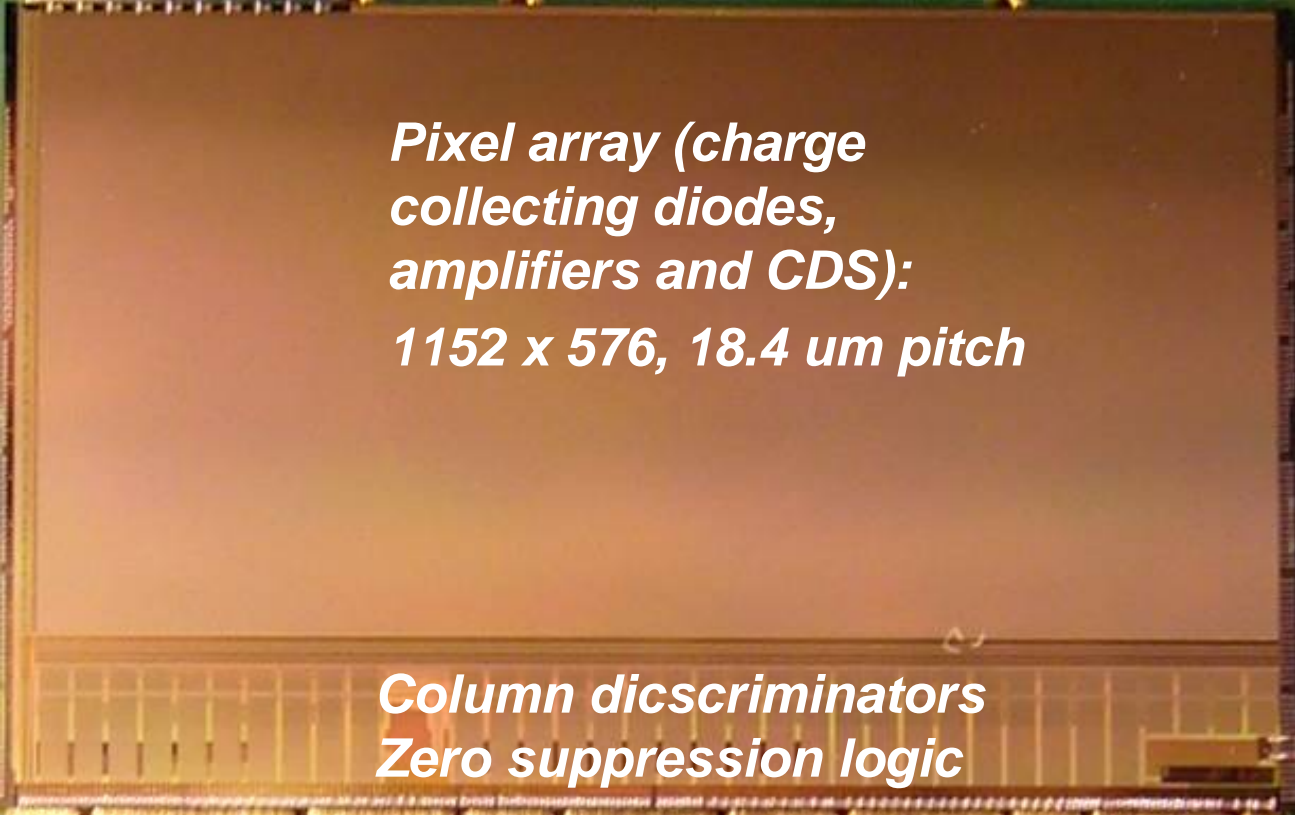


high resistivity ($1\text{k}\Omega\cdot\text{cm}$) P-epi:
size of depletion zone size is
comparable to the P-epi thickness!

Sensor (Mimosa26) for EUDET beam telescope

$10.6 \times 21.2 \text{ mm}^2$

CMOS AMS 0.35 μm
OPTO process, epi-
layer 400 $\text{Ohm}\cdot\text{cm}$



*Pixel array (charge
collecting diodes,
amplifiers and CDS):
1152 x 576, 18.4 μm pitch*

*Column discriminators
Zero suppression logic*

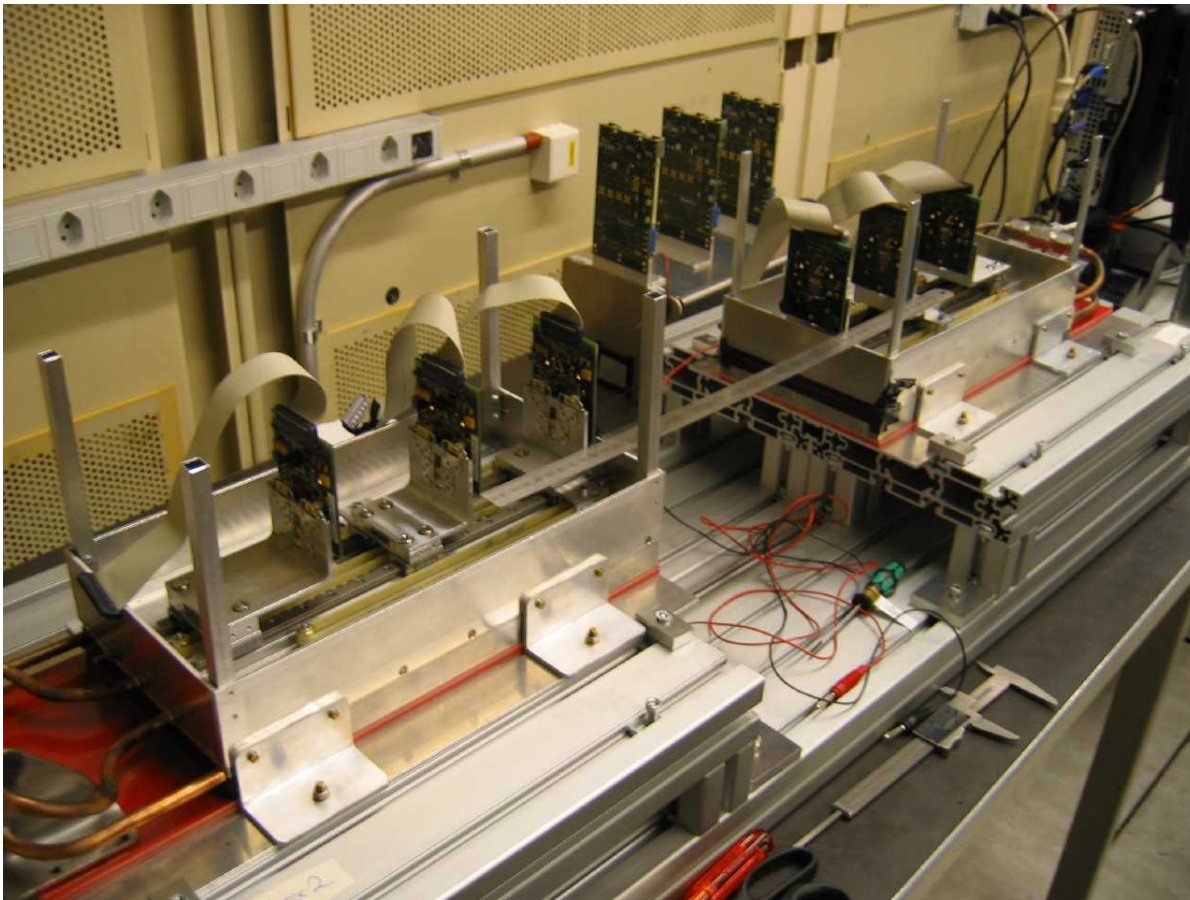
Read-out in rolling-
shutter mode:
80 MHz clock (can
work up to 115MHz),
115.2 μs (down to
 $\sim 85 \mu\text{s}$) integration
time

binary signal readout

zero suppression in 18 groups
of 64 columns allowing ≤ 9
"pixel strings" / row

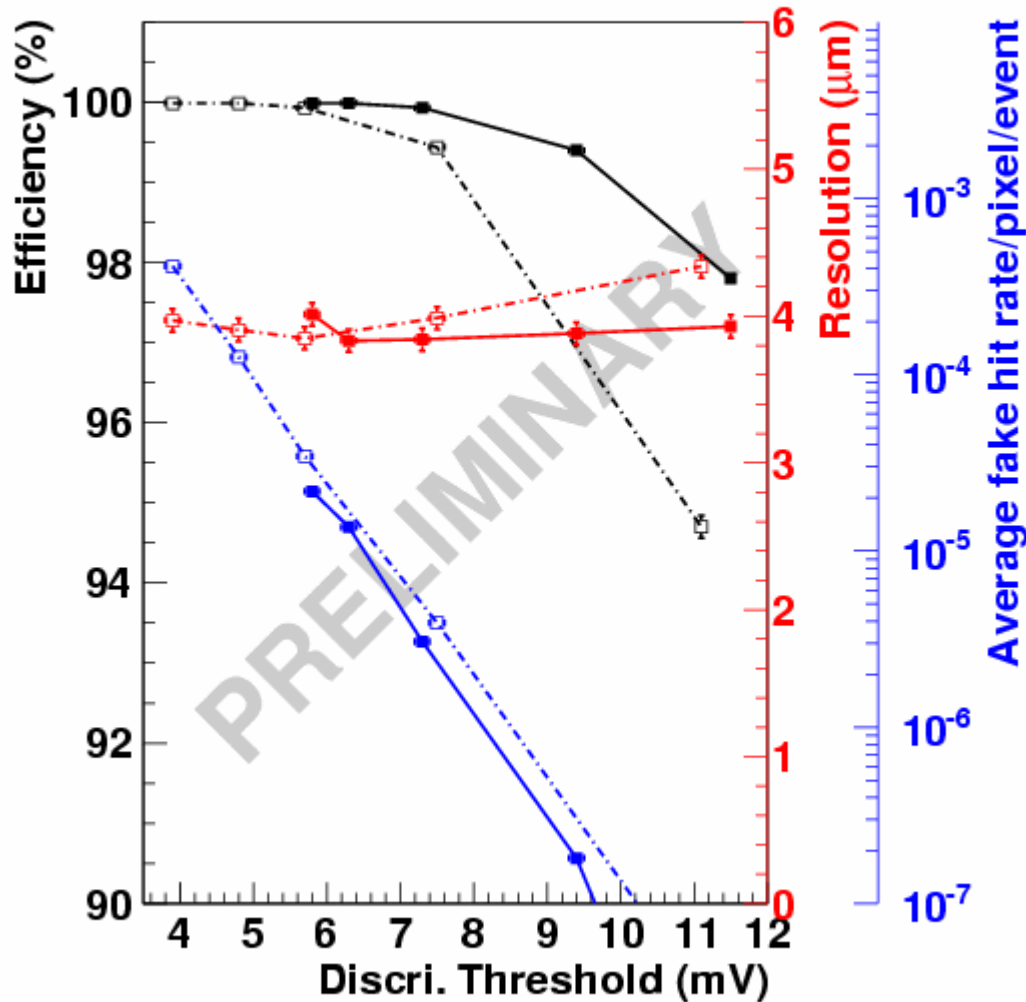
EUDET beam telescope

- 2 arms of 3 planes
- Mimoso26 thinned to 50 μm
- extrapolated 1-2 μm EVEN with e^- (3 GeV, DESY)
- frame read-out frequency $O(10^4)$ Hz
- running since '07 (demonstrator: analogues outputs) at CERN-SPS & DESY



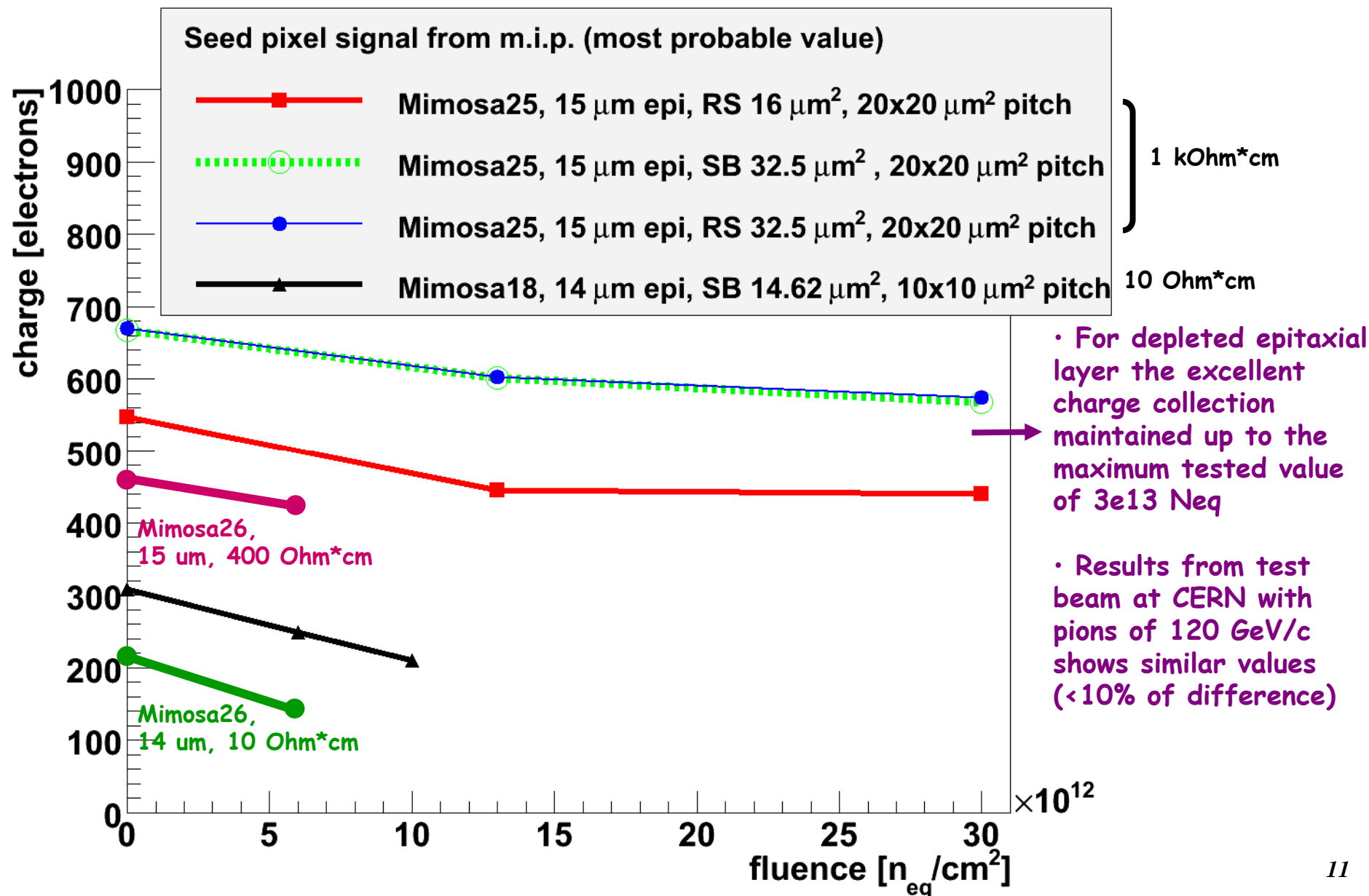
EUDET beam telescope sensor performance

Mi26 HR-15 and HR-10 Efficiency, Fake rate and Resolution



- non-irradiated
- thinned down to 50 μm
- 20 C temperature
- 400 $\text{Ohm}\cdot\text{cm}$ epitaxial layer
- 15 μm and 10 μm thickness of epitaxial layer

Comparison of charge collection from Ru106 source for irradiated sensors



Mimosa26 sensor as a prototype for the STAR HFT

Mimosa26 sensor

- 80 MHz
- 115.2 us integration time
- temperature ~ 20C
- 1152 x 576 pixels matrix
- 18.4 um pitch
- no constrains on radiation tolerance

ULTIMATE sensor (chip submission October 2010), design in progress

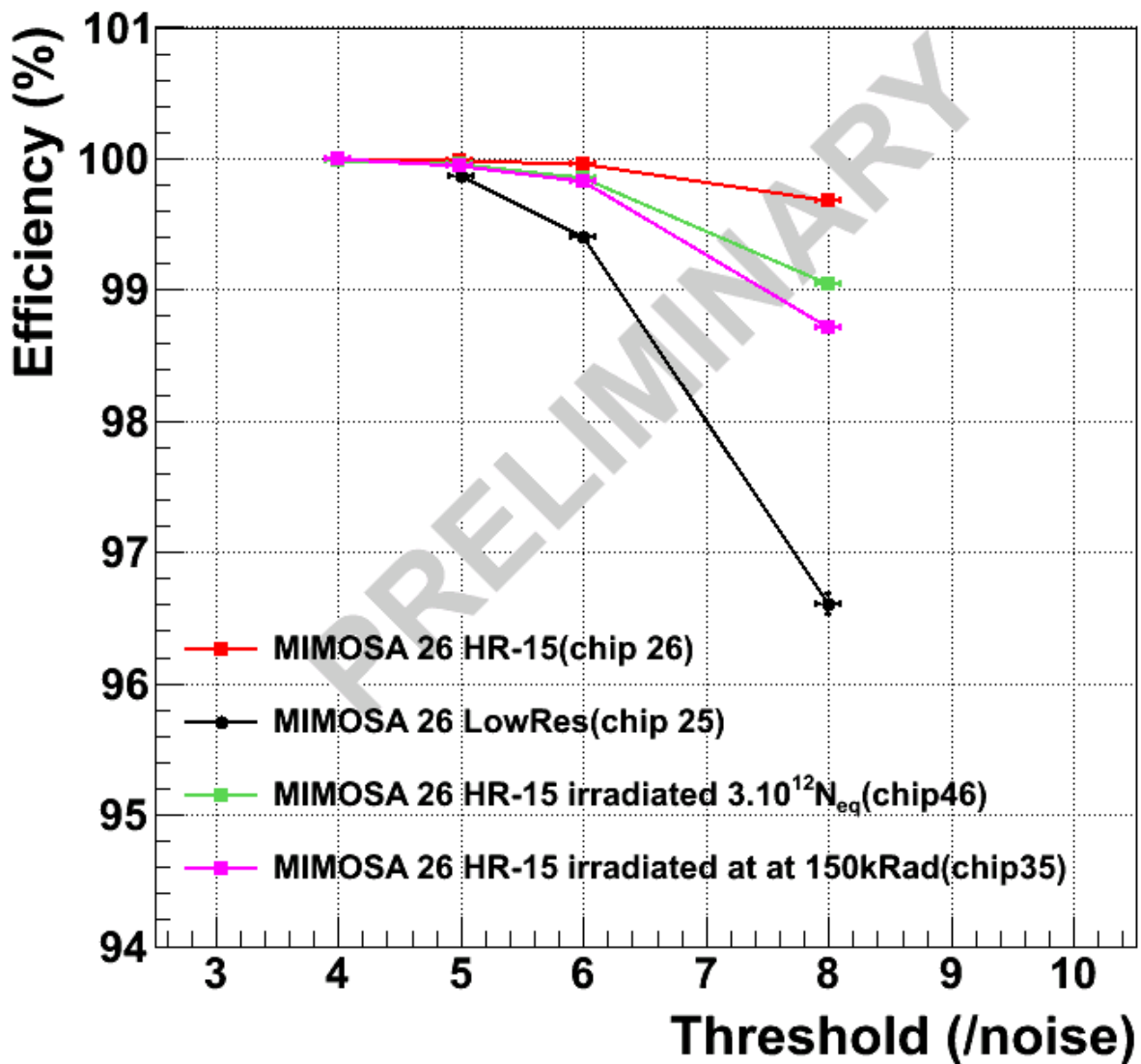
- larger matrix, integration time will be larger (<200 us)
- temperature +30 +35C
- 960 x 928 pixels matrix
- 20.7 um pitch, to fit power consumption constraints (< 135 mW/cm²)
- 150 kRad ionizing radiation
- 3e12 Neq/cm² non-ionizing radiation



1. need to improve charge collection, radiation tolerance -> high resistivity epitaxial layer
2. improvement of radiation tolerance of pixel design

Mimosa26 sensor in a high-resistivity epitaxial layer

Efficiency vs Threshold

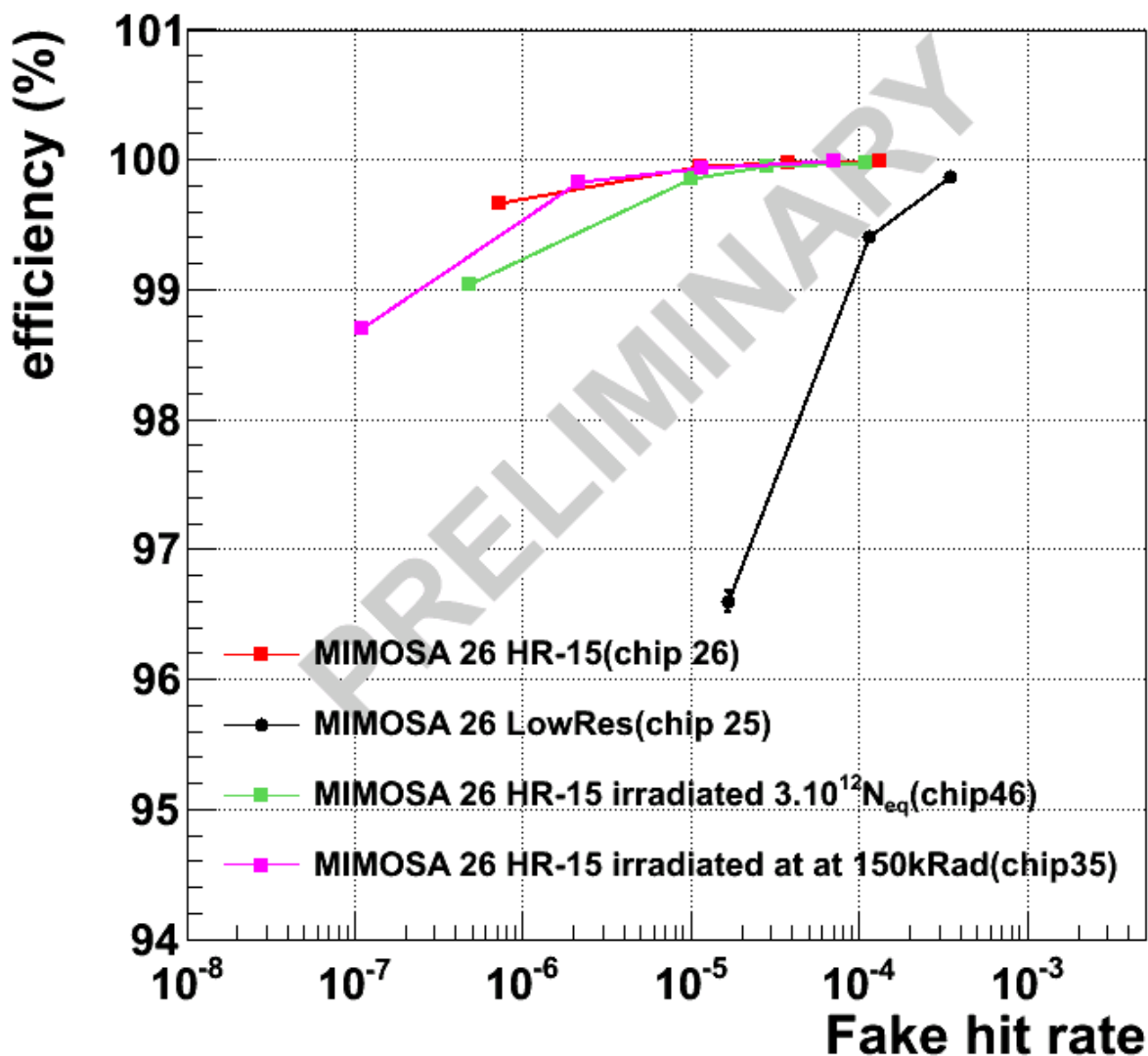


- 50 MHz to emulate longer integration time
- +35 C temperature!

resolution < 5um

Mimosa26 sensor in a high-resistivity epitaxial layer

Efficiency vs Fake hit rate



- 50 MHz to emulate longer integration time
- +35 C temperature !

resolution < 5um

Prototyping for optimization: Mimosa22ahr - tests of several pixel variants

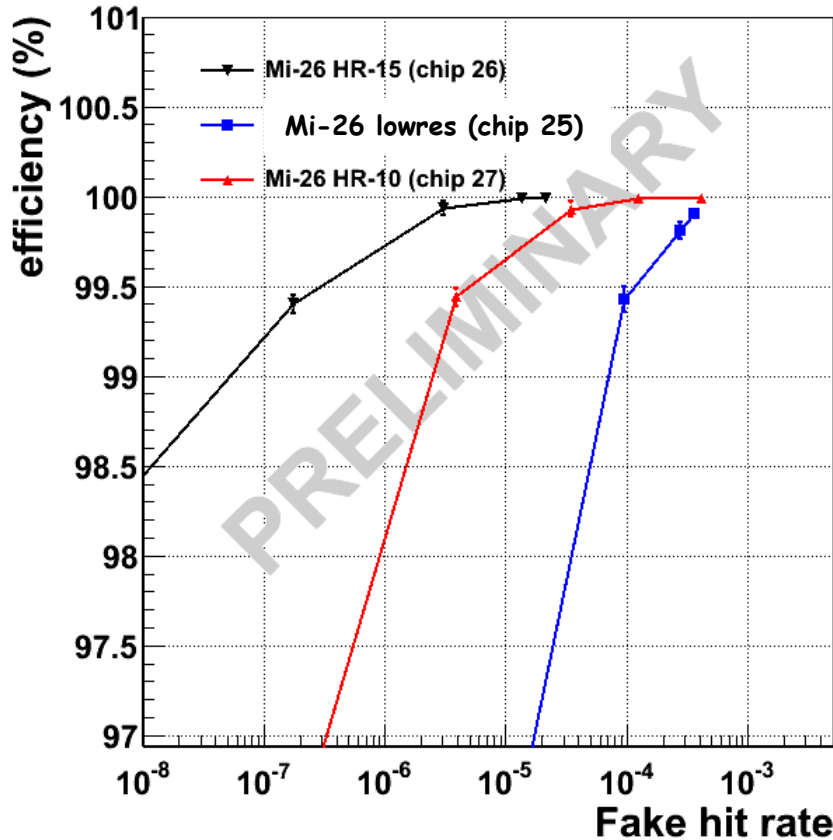
- pitch 20.7 μm and 18.4 μm
- few diode sizes , from 11 μm^2 to 18 μm^2
- radiation tolerant designs (ELT)
- diode bias voltage increase
- two stage amplifiers, AC coupling

Lab test with Fe55 at +35 C and integration time imposed by the STAR requirements shows:

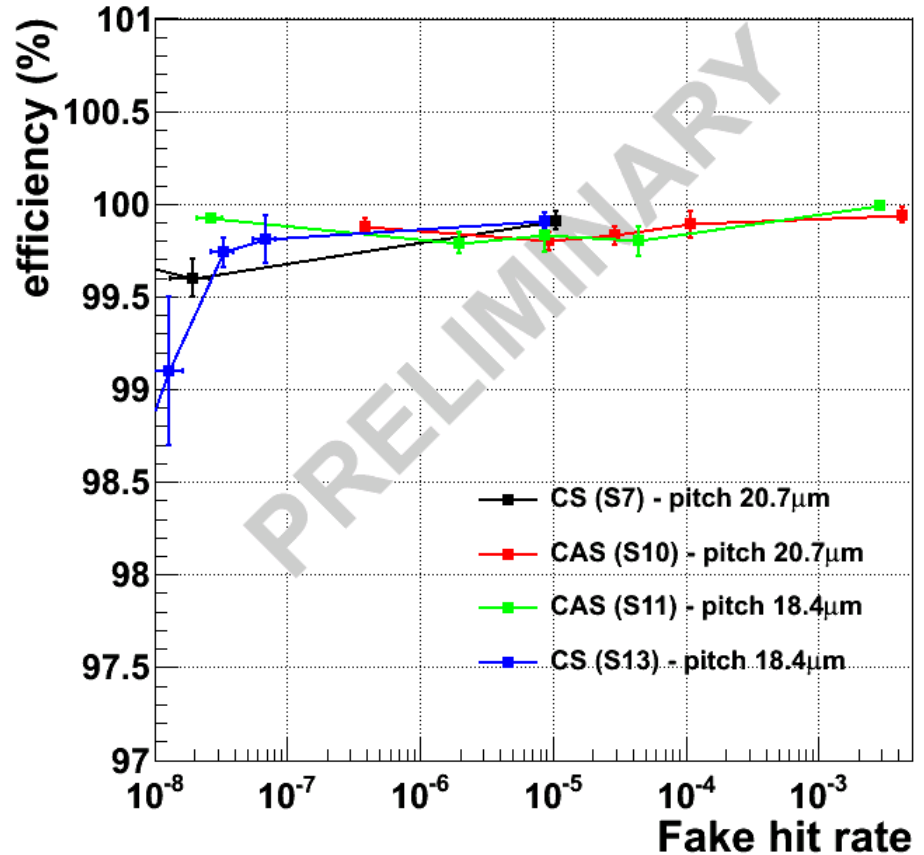
- the conversion gain can be improved by factor of two
- noise before irradiation 10 to 13 e
- noise after irradiation with 150 kRad is from 13 to 23 e
- noise after irradiation with $3e12$ Neq is from 16 to 23 e
- SNR up to 30 after irradiation
- for a low resistivity epitaxial layer ~ 30 before irradiation

Mimosa22ahr - beam tests (CERN-SPS)

Efficiency vs Fake hit rate



Efficiency vs Fake hit rate



- 100 MHz
- ~ 20 C temperature
- non-irradiated
- resolution < 5 μm

Conclusions

- The high resistivity epitaxial layer improves signal-to-noise ratio of MAPS, confirmed in a beam test with Mimosa26 -> efficiency >99.8% (at $10e-5$ fake hit rate)
 - > In particular the radiation tolerance is highly improved ($NI \times 100$)
- The radiation hardness can still be improved by pixel design, first lab results of Mimosa22ahr + beam test measurements are in progress..
- PIXEL detector for the STAR experiment based on a modified version of Mimosa26 Sensors built in a high resistivity epitaxial layer will fulfill the STAR HFT requirement
 - > ULTIMATE sensor is going to be submitted for fabrication autumn 2010